Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	997118	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON .	2006/12/08 09:01
S2	5837	antireflective adj coating	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 11:01
S3	311	S1 near S2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 09:24
S4	3499	430/322	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR .	ON	2006/11/29 15:52
S8.	14355	amorphous adj carbon	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	·ON	2006/12/01 09:25
S9	997779	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR -	ON	. 2006/12/01 09:25

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S10	48	S8 near S9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 09:25
S11	629939	antireflect\$3 or ARC	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 11:01
S13	384	carbon near mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 11:02
S14	975	S9 near S11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 11:00
S15		S9 near S13	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/01 11:03
S19	662	ammonium adj hydroxide same hydrogen adj peroxide same aqueous adj solution	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 13:02
S20	998106	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR •	ON	2006/12/04 13:03

S21	136	S19 and S20	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:35
S22	40	S19 same S20	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 13:04
S23	2006	sulfuric adj acid same citric adj acid same aqueous adj solution	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 15:43
S24	998106	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 15:44
S25	243	S23 and S24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/04 15:44
S26	49	S23 same S24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR .	ON	2006/12/04 15:44
S27	6209164	remov\$3 or strip\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:36

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S28	663	ammonium adj hydroxide same hydrogen adj peroxide same aqueous adj solution	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:36
S29	998490	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:36
S30	32	S27 same S28 same S29	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:38
S31	2008	sulfuric adj acid same citric adj acid same aqueous adj solution	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 09:39
S32 .	19	S27 same S31 same S29	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 11:18
S33	2	("5039349").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	OFF	2006/12/05 09:40
S35	2	"20050104114".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR .	ON	2006/12/05 09:47

S37	6209164	remov\$3 or strip\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/06 16:18
S38	998490	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 11:18
S39	2008	sulfuric adj acid same citric adj acid same aqueous adj solution	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 11:18
S40	. 224	S37 and S39 and S38	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/05 11:18
S43	23	("20010051440" "20030008513" " 20030222241" "20040101784" "57 83495" "5990019" "6235145" "63 50706" "6453914" "6517738" "65 89884" "6783695").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T; IBM_TDB	OR	ON	2006/12/08 15:18